## 2025년 2월 12일(수)-14일(금) | 강원도 하이원리조트

## Future Normal in Semiconductor

2025년 2월 14일(금), 15:10-17:10 Room E(에메랄드 II+III), 5층

# D. Thin Film Process Technology 분과 071\_[FE3-D] TFT/Memory

#### 좌장: 윤성민 교수(경희대학교), 전우진 교수(경희대학교)

-	osition-Dependent Threshold Voltage Variation in GeSeTe-Based
FE3-D-1 Select	or-Only Memory Device
15:10-15:25 Young	⁄un Mun and Gun Hwan Kim
Departr	nent of System Semiconductor Engineering, Yonsei University
Explor	ng TiO <sub>2</sub> Interlayer Impact on H <sub>x</sub> Z <sub>1-x</sub> O <sub>2</sub> Ferroelectric Stability and
FE3-D-2 Perfor	mance in Cryogenic Memory Applications
So-Yeo	ng Park, Woon-San Ko, Do-Yeon Lee, So-Yeon Kwon, Hye-Ri Hong, Seong-Jo
15:25-15:40 Jo, and	Ga-Won Lee
Departr	nent of Electronics Engineering, Chungnam National University
A New	Structure for High-Performance Operation of Oxide and Organic
Semic	onductor Heterojunction Transistors: Spatially Separating Layer
FE3-D-3 Sandw	riched Anti-Ambipolar Transistor
15:40-15:55 Youngn	nin Han <sup>1</sup> and Hocheon Yoo <sup>1,2</sup>
<sup>1</sup> Depart	ment of Semiconductor Engineering, Gachon University, <sup>2</sup> Department of
Electror	nic Engineering, Gachon University
Study	on the Enhancement of HfO <sub>2</sub> Dielectric Properties Using SiCN
FE3-D-4 Cappir	ng Layer
	Hong, Woon-San Ko, Do-Yeon Lee, So-Yeon Kwon, So-Yeong Park, Seong-Jo
Jo, and	Ga-Won Lee
Chungr	am National University
Deterr	nination of Subgap DOS over the Wide Energy Range Using Multi-
FE3-D-5 Wavel	ength Light in PEALD Cu₂O TFTs
Soveon	Kim <sup>1</sup> , Jaewook Yoo <sup>1</sup> , Seongbin Lim <sup>1</sup> , Hyeonjun Song <sup>1</sup> , Hongseung Lee <sup>1</sup> ,
16:10-16:25 Seohye	on Park <sup>1</sup> , Minah Park <sup>1</sup> , Sojin Jeong <sup>1</sup> , Peide D. Ye <sup>2</sup> , and Hagyoul Bae <sup>1</sup>
<sup>1</sup> Jeonbi	uk National University, <sup>2</sup> Purdue University, USA



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FE3-D-6 16:25-16:40	Multimode Operation of Light-Gated Transistors based on Millimeter-Scale  Transition-Metal Dichalcogenide Grown by Chemical Vapor Deposition  Wonbeom Kim <sup>1</sup> , Somnath S. Kundale <sup>3</sup> , Hyeongtae Kim <sup>1</sup> , Su-Yeon Cho <sup>1</sup> , Mi Ji Kwon <sup>1</sup> ,  Soobin Shim <sup>1</sup> , and Jun Hong Park <sup>2</sup> <sup>1</sup> Department of Materials Engineering and Convergence Technology, Gyeongsang  National University, <sup>2</sup> Department of Materials Engineering and Convergence Technology
	and School of Materials Science and Engineering, Gyeongsang National University, <sup>3</sup> Research Institute for Green Energy Convergence Technology, Gyeongsang National University
	Defect-selective Platinum Nanoparticle Functionalization of 2D WS <sub>2</sub> by
FE3-D-7 16:40-16:55	Atomic Layer Deposition for Enhancing Gas Sensing Properties
	Minji Kim, Inkyu Sohn, Dain Shin, Jaehyeok Kim, Tatsuya Nakazawa, Seung-min Chung
	and Hyungjun Kim
	School of Electrical and Electronic Engineering, Yonsei University
	High-Performance p-Type Tin Halide Perovskite Transistor with Non-
	Volatile Methylammonium Chloride
	Hansol Park <sup>1,2</sup> , Jongmin Lee <sup>1,2</sup> , Cheong Beom Lee <sup>3</sup> , Kyeounghak Kim <sup>4</sup> , and Hui Joon
FE3-D-8	Park <sup>1,2</sup> , <sup>5</sup>
16:55-17:10	<sup>1</sup> Department of Organic and Nano Engineering, Hanyang University, <sup>2</sup> Human-Tech
	Convergence Program, Hanyang University, <sup>3</sup> Department of Chemistry, Hanyang
	University, <sup>4</sup> Department of Chemical Engineering, Hanyang University, <sup>5</sup> Department of
	Semiconductor Engineering, Hanyang University